

AG/ 1765 Gen

Docket No. 56775 (70551)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

N. Kanetsuki, et al.

EXAMINER: L. Vinh

DO NOT ENTER

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Plasma Processing Method

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RESPONSE TO FINAL OFFICE ACTION

The following is in response to the Office Action mailed February 24, 2004, in the above referenced application.

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.